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FORM PTO - 1449 SUPPLEMENTAL INFORMATION <i>1 P E</i> DISCLOSURE STATEMENT					ATTY DOCKET NO.: ASC-044C1 APPLICANT(S): Fitzgerald <i>et al.</i> SERIAL NO.: 10/611,739 FILING DATE: July 1, 2003 GROUP: 2818				
U.S. PATENT DOCUMENTS									
EXAM. INIT.		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE		
<i>11</i>	A140	4,987,462	01/22/1991	Kim <i>et al.</i>	357	22	01/06/1987		
	A141	5,240,876	08/31/1993	Gaul <i>et al.</i>	437	131	06/01/1992		
	A142	5,424,243	06/13/1995	Takasaki	437	132	09/09/1994		
	A143	5,572,043	11/05/1996	Shimizu <i>et al.</i>	257	18	03/15/1995		
	A144	5,786,614	07/28/1998	Chuang <i>et al.</i>	257	318	04/08/1997		
	A145	6,352,909	03/05/2002	Usenko	438	438	05/26/2000		
	A146	6,524,935	02/25/2003	Canepari <i>et al.</i>	438	478	09/29/2000		
	A147	6,646,322	11/11/2003	Fitzgerald	257	531	07/16/2001		
	A148	6,677,192	01/13/2004	Fitzgerald	438	172	07/16/2001		
	A149	6,703,144	03/09/2004	Fitzgerald	428	641	03/18/2003		
	A150	6,703,688	03/09/2004	Fitzgerald	257	616	7/16/2001		
	A151	6,709,903	03/23/2004	Christiansen	438	149	04/30/2003		
FOREIGN PATENT DOCUMENTS									
EXAM. INIT.		DOCUMENT NUMBER	DATE	COUNTRY CODE	CLASS	SUB CLASS	FILING DATE	ABSTRACT ONLY	ENGLISH LANG (Y/N)
<i>11</i>	B44	2004/006327	01/15/2004	WO					Y
<i>11</i>	B45	2004/006311	01/15/2004	WO					Y
<i>11</i>	B46	61-141116	06/28/1986	JP					Y (abstract only)
<i>11</i>	B47	2-210816	08/22/1990	JP					Y (abstract only)
<i>11</i>	B48	3-036717	02/18/1991	JP					Y
EXAM. INIT.	OTHER DOCUMENTS: (Including Author, Title, Date, Relevant Pages, Place of Publication)								
<i>11</i>	C92	Grillot <i>et al.</i> , "Acceptor diffusion and segregation in (Al _x Ga _{1-x}) _{0.3} In _{0.7} P heterostructures," <i>Journal of Applied Physics</i> , Vol. 91, No. 8 (2002), pp. 4891-4899.							
<i>11</i>	C93	Halsall <i>et al.</i> , "Electron diffraction and Raman studies of the effect of substrate misorientation on ordering in the AlGInP system," <i>Journal of Applied Physics</i> , Vol. 85, No. 1 (1999), pp. 199-202.							
<i>11</i>	C94	Hsu <i>et al.</i> , "Surface morphology of related Ge _x Si _{1-x} films," <i>Appl. Phys. Lett.</i> , Vol. 61, No. 11 (1992), pp. 1293-1295.							
EXAMINER <i>11</i>				DATE CONSIDERED			<i>Sept - 2004</i>		

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U.S. PATENT DOCUMENTS							
EXAM. INIT.		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
	A152	6,713,326	03/30/2004	Cheng <i>et al.</i>	438	149	03/04/2003
	A153	6,723,661	04/24/2003	Fitzgerald	438	763	07/16/2001
	A154	6,737,670	05/18/2004	Cheng <i>et al.</i>	257	19	03/07/2003
	A155	6,750,130	06/15/2004	Fitzgerald	438	607	01/07/2001
	A156	2002/0084000	07/04/2002	Fitzgerald	148	33.2	12/17/2001
	A157	2003/0034529	02/20/2003	Fitzgerald <i>et al.</i>	257	369	10/08/2002
	A158	2003/0102498	06/05/2003	Braithwaite <i>et al.</i>	257	288	09/24/2002
	A159	2003/0199126	10/23/2003	Chu <i>et al.</i>	438	149	04/23/2002
	A160	2003/0203600	10/30/2003	Chu <i>et al.</i>	438	479	06/28/2003
	A161	2003/0215990	11/20/2003	Fitzgerald <i>et al.</i>	438	172	03/14/2003
	A162	2003/0218189	11/27/2003	Christiansen	257	200	11/19/2002
	A163	2003/0227057	12/1/2003	Lochtefeld <i>et al.</i>	257	347	10/04/2002
	A164	2004/0005740	01/01/2004	Lochtefeld <i>et al.</i>	438	149	06/06/2003
	A165	2004/0014304	01/22/2004	Bhattacharyya	438	570	07/18/2002
	A166	2004/0031979	01/01/2004	Lochtefeld	257	233	06/06/2003
	A167	2004/0041210	03/04/2004	Mouli	257	347	09/02/2003
	A168	2004/0075149	04/22/2004	Fitzgerald <i>et al.</i>	257	369	07/23/2003
EXAM. INIT.	OTHER DOCUMENTS: (Including Author, Title, Date, Relevant Pages, Place of Publication)						
	C95	IBM Technical Disclosure Bulletin, Volume 32, No. 8A, January 1990, "Optimal Growth Technique and Structure for Strain Relaxation of Si-Ge Layers on Si Substrates", pp. 330-331.					
	C96	Ota, Y. <i>et al.</i> , "Application of heterojunction FET to power amplifier for cellular telephone," Electronics Letters, Vol. 30 No. 11 (May 26, 1994) pp. 906-907.					
	C97	Sakaguchi <i>et al.</i> , "ELTRAN® by Splitting Porous Si Layers," Proc. 195th Int. SOI Symposium, Vol. 99-3, Electrochemical Society (1999) pp. 117-121.					
EXAMINER				DATE CONSIDERED			
Dle				Sept - 2004			

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